

**IN THE UNITED STATES PATENT AND TRADEMARK OFFICE**

In re Application of	:	Customer No.: 53080
	:	
Akio MISAKA	:	Confirmation No.: 7423
	:	
Application No.: 10/576,120	:	Group Art Unit: 1795
	:	
Filed: April 18, 2006	:	Examiner: Rashid A. ALAM
	:	
For: PHOTOMASK (as amended)	:	

**AMENDMENT TO ACCOMPANY RCE**

Mail Stop RCE  
Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

Sir:

In response to the Office Action dated August 21, 2009, wherein a three-month shortened statutory period for response is set to expire on November 21, 2009, Applicant respectfully requests reconsideration of the above-identified application in view of the following amendments and remarks. A request for continued examination is being concurrently filed herewith.